

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

December 5, 2025

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG754527574

LABORATORY GROWN DIAMOND

EMERALD CUT

9.69 X 6.92 X 4.70 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

3.07 CARATS

G

VVS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence


EXCELLENT

EXCELLENT

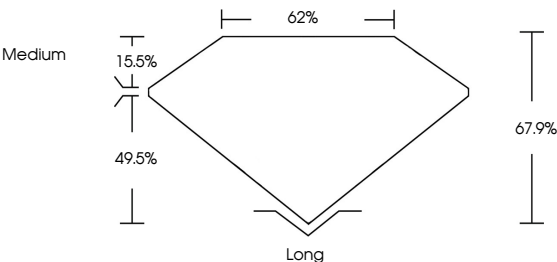
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Inscription(s)

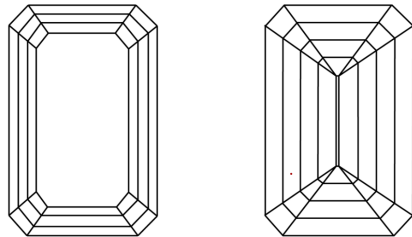
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

 LG754527574

PROPORTIONS



CLARITY CHARACTERISTICS




KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

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
EXCELLENT

EXCELLENT

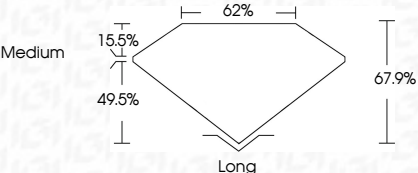
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PROPORTIONS



IGI



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Carat Weight

Color Grade

Clarity Grade

Depth

Table

Graile

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

3.07 CARATS

G

VVS 1

67.9%

62%

Medium

Long

EXCELLENT

EXCELLENT

NONE

 LG754527574

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